Applicant : Martin Lambert Attorney's Docket No.: 15540-010001 / 25620; Serial No.: 10/678.753 18.00277; DS08080

Serial No.: 10/678,753 Filed: October 6, 2003

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Amendments to the Claims:

This listing of claims replaces all prior versions and listings of claims in the application:

Listing of Claims:

1. (Currently Amended) A laser processing machine comprising:

a beam guiding chamber adapted for flushing with a flushing gas, the beam chamber comprising an inner chamber; and

a pressure relief valve coupled to the beam guiding chamber for releasing the flushing gas from the beam guiding chamber, the pressure relief valve sealing the beam chamber when closed, and being configured to release pressure from the inner chamber only when an internal pressure in the inner chamber reaches a predetermined level, the pressure relief valve comprising

a valve chamber in fluid communication with the inner chamber, and
a moveable valve disk configured to seal the valve chamber when the pressure
relief valve is closed.

- 2. (Cancelled)
- 3. (Cancelled)
- 4. (Currently Amended) The laser processing machine of claim 1 [[3]], wherein the movably-disposed valve disk is attached to a pin movably located within a chamber of the pressure relief valve.
- 5. (Original) The laser processing machine of claim 1, wherein the beam guiding chamber is adapted for flushing with a flushing gas at an overpressure compared to an atmosphere surrounding the beam guiding chamber.

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6. (Original) The laser processing machine of claim 5, wherein the pressure relief valve is adapted to be opened passively when the overpressure within the beam guiding chamber exceeds a critical overpressure.

7. (Currently Amended) A method of flushing a beam guiding chamber of a laser processing machine, the method comprising:

flushing the beam guiding chamber with a flushing gas; and releasing a portion of the flushing gas from the beam guiding chamber through a pressure relief valve,

the pressure relief valve sealing the beam chamber when closed, and being configured to release pressure from the inner chamber only when an internal pressure in the inner chamber reaches a predetermined level, the pressure relief valve comprising

a valve chamber in fluid communication with an inner chamber of the beam guiding chamber, and a moveable valve disk configured to seal the valve chamber when the pressure relief valve is closed, and to define an annular gap when the pressure relief valve is open..

- 8. (Original) The method of claim 7, further comprising flushing the beam guiding chamber with a flushing gas having an overpressure compared to an atmosphere surrounding the beam guiding chamber.
- 9. (Original) The method of claim 8, wherein the flushing gas is passively released through the pressure relief value due to the overpressure of the gas acting on the valve to open the valve when the overpressure exceeds a predetermined overpressure.
- 10. (New) The laser processing machine of claim 4 wherein the pin is attached to the center of the valve disk, and the pin is configured to move axially to move the disk in a direction generally perpendicular to the plane of the disk.

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11. (New) The laser processing machine of claim 10 further comprising an annular seal against which a peripheral edge of the disk seats when the pressure relief valve is closed.

- 12. (New) The laser processing machine of claim 11 wherein the weight of the pin is selected so that the disk can only be displaced sufficiently to break contact between the annular seal and peripheral edge when the predetermined internal pressure is exceeded.
- 13. (New) The laser processing machine of claim 11 wherein the pressure relief valve is configured so that the peripheral edge and annular seal define an annular gap when the pressure relief valve is open.
- 14. (New) The method of claim 7 wherein the valve disk is attached to a pin movably located within a chamber of the pressure relief valve.
- 15. (New) The method of claim 14 wherein the pin is attached to the center of the valve disk, and the pin is configured to move axially to move the disk in a direction generally perpendicular to the plane of the disk.
- 16. (New) The method of claim 15 further comprising providing the pressure relief valve with an annular seal against which a peripheral edge of the disk seats when the pressure relief valve is closed.
- 17. (New) The method of claim 16, further comprising selecting the weight of the pin so that the disk can only be displaced sufficiently to break contact between the annular seal and peripheral edge when the predetermined internal pressure is exceeded.